

PATENT Customer No. 22,852 Attorney Docket No. 4329.3191

## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:	)
Shigeki NOJIMA et al.	) Group Art Unit: 1756
Application No.: 10/724,738	) Examiner: Rosasco, Stephen D.
Filed: December 2, 2003	) )
For: METHOD OF MANUFACTURING A PHOTO MASK AND METHOD OF MANUFACTURING A SEMICONDUCTOR DEVICE	Confirmation No.: 2083 ) ) )

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

## **AMENDMENT**

In reply to the Office Action mailed September 29, 2005, the period for response to which has been extended through January 30, 2006 (January 29, 2006, being a Sunday), by a petition for a one month extension of time, Applicants amend this application as follows:

Amendments to the Specification begin on page 2 of this paper.

Amendments to the Claims are reflected in the listing of claims on page 3 of this paper.

Remarks begin on page 7 of this paper.